What is claimed is:

- 1. A masking material for dry etching of a magnetic material by using a mixed gas of carbon monoxide and a nitrogenous compound as etching gas, which comprises a metal having a specific physical property that its melting or boiling point, when it is converted into a nitride or carbide is higher than that of in the form of single metel.
- The masking material for dry etching according to claim
 , wherein the metal is tantalum.
- 3. The masking material for dry etching according to claim
- 1, wherein the metal is tungsten, zirconium or hafnium.